
**Fine ceramics (advanced ceramics,
advanced technical ceramics) —
Test method for air-purification
performance of semiconducting
photocatalytic materials —**

**Part 1:
Removal of nitric oxide**

*Céramiques techniques — Méthodes d'essai relatives à la performance
des matériaux photocatalytiques semi-conducteurs pour la
purification de l'air —*

Partie 1: Élimination de l'oxyde nitrique



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